

Determination of Energy-Level Alignment in Molecular Tunnel Junctions by Transport and Spectroscopy: Self-Consistency for the Case of Oligophenylene Thiols and Dithiols on Ag, Au, and Pt Electrodes

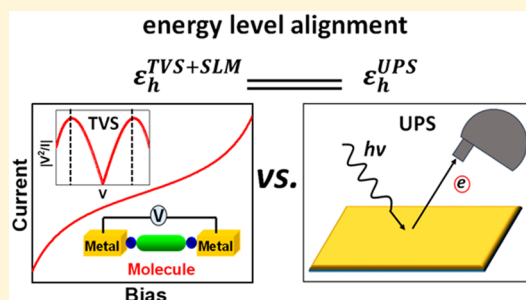
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Supporting Information

ABSTRACT: We report detailed measurements of transport and electronic properties of molecular tunnel junctions based on self-assembled monolayers (SAMs) of oligophenylene monothiols (OPT n , $n = 1–3$) and dithiols (OPD n , $n = 1–3$) on Ag, Au, and Pt electrodes. The junctions were fabricated with the conducting probe atomic force microscope (CP-AFM) platform. Fitting of the current–voltage ($I–V$) characteristics for OPT n and OPD n junctions to the analytical single-level tunneling model allows extraction of both the HOMO-to-Fermi-level offset (ϵ_h) and the average molecule–electrode coupling (Γ) as a function of molecular length (n) and electrode work function (Φ). Significantly, direct measurements of ϵ_h^{UPS} by ultraviolet photoelectron spectroscopy (UPS) for OPT n and OPD n SAMs on Ag, Au, and Pt agree remarkably well with the transport estimates $\epsilon_h^{\text{trans}}$, providing strong support—beyond the high quality $I–V$ simulations—for the relevance of the analytical single-level model to simple molecular tunnel junctions. Because the UPS measurements involve SAMs bonded to only one metal contact, the correspondence of ϵ_h^{UPS} and $\epsilon_h^{\text{trans}}$ also indicates that the top contact has a weak effect on the HOMO energy. Corroborating ab initio calculations definitively rule out a dominant contribution of image charge effects to the magnitude of ϵ_h . Thus, the effective molecular tunnel barrier ϵ_h is determined, and essentially pinned, by the formation of a single metal–S covalent bond per OPT n or OPD n molecule.



INTRODUCTION

Relating charge-transport properties to the electronic structure of metal–molecule–metal junctions is an important fundamental goal for the field of molecular electronics that is essential to the rational design of junctions with prescribed current–voltage ($I–V$) behavior.^{1–22} Generally speaking, the approach taken by many research groups is to compare conductance measurements (typically not full $I–V$ behavior) with the predictions of density functional theory (DFT) calculations.^{23–30} In this case, DFT is employed (1) to estimate the electronic structure of the junction,^{23–30} e.g., the offset (ϵ_h or ϵ_l) of the HOMO or LUMO from the junction Fermi level, and the molecule–electrode coupling (Γ), Figure 1A and (2) to compute the electron or hole transmission function as a function of applied bias.^{25–34} The correspondence of the calculation with the experimental conductance measurements (usually over a limited voltage window, perhaps even just at a single voltage) is employed to establish the charge transport–electronic structure relationship.

It is of course desirable to have an independent experimental measurement of electronic structure inside a nanoscale metal–molecule–metal junction that can be compared to quantum

chemical calculations. Molecular junctions employing a gate electrode enable transport spectroscopy that indeed provides transport and electronic structure information simultaneously on single molecules or molecular ensembles, facilitating comparisons to computational predictions.^{5,35–40} This elegant approach to the transport–electronic structure problem is not available for two-terminal molecular junctions. It is desirable to address this issue, namely to find a way to extract electronic structure information directly from two terminal transport measurements and to compare the results with an independent spectroscopic measurement. This provides a consistency check and substantiation (or required revision) of the proposed transport–electronic structure relationship. Accomplishing this for simple two terminal molecular junctions is the goal of this report.

Recent work by the authors, independently⁴¹ and collaboratively,^{42–47} has shown that the compact, analytical single-level model (SLM), derived from the Landauer picture and subject to certain approximations, can be employed

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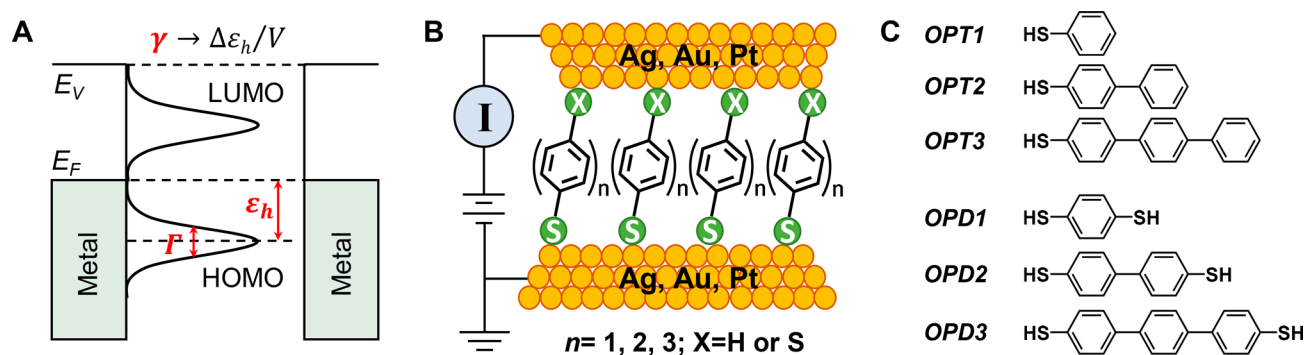


Figure 1. (A) Typical molecular junction electronic structure with key parameters ϵ_h , Γ , and γ . (B) Schematic representation of the CP-AFM junction. A metal-coated AFM tip is brought into contact with a SAM of OPT n or OPD n on Ag, Au, or Pt substrates. (C) Molecular structures of OPT1–3 and OPD1–3.

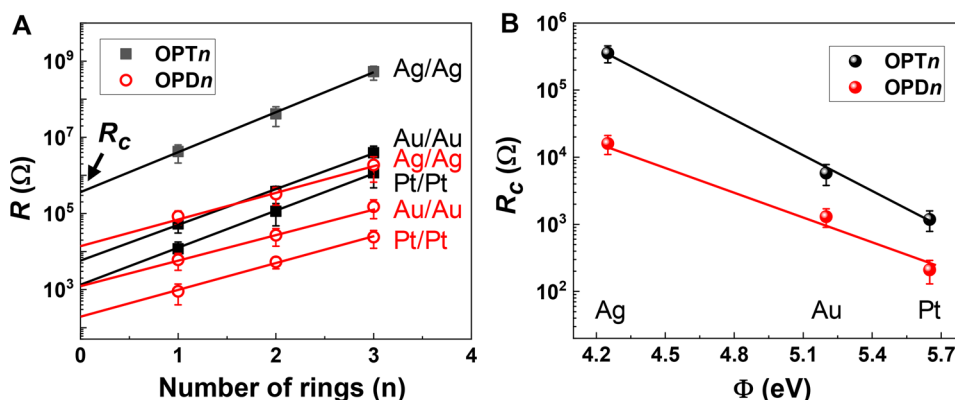


Figure 2. (A) Semilog plot of low-bias resistance for OPT n and OPD n versus number of phenyl rings ($n = 1-3$). (B) Contact resistance (R_c) for OPT n and OPD n versus the work functions of the electrodes. The work function of the bare Ag, Au, and Pt electrodes are 4.25 eV, 5.2 eV and 5.65 eV, respectively.

productively to extract the HOMO (or LUMO) position $\epsilon_h^{\text{trans}}$ (or $\epsilon_l^{\text{trans}}$) and the molecule–electrode coupling Γ from junction I – V characteristics. Validation for the SLM has so far included (1) its ability to fit the I – V characteristics for a wide variety of simple molecular junctions extremely well with physically reasonable values for $\epsilon_h^{\text{trans}}$ and Γ and (2) its prediction of a universal master curve that precisely matches the I – V characteristics of molecular junctions consisting of aliphatic and aromatic molecules with conductances varying over 5 orders of magnitude.^{45,48} In this paper, we employ the SLM to extract $\epsilon_h^{\text{trans}}$ and Γ for junctions based on self-assembled monolayers (SAMs) of two series of molecules, oligophenylene monothiods (OPT n , $n = 1,2,3$) and dithiods (OPD n , $n = 1-3$), on Ag, Au, and Pt electrodes, Figure 1. We then compare $\epsilon_h^{\text{trans}}$ obtained from the transport analysis of the 18 different junctions to 18 values of ϵ_h^{UPS} measured independently by ultraviolet photoelectron spectroscopy (UPS) for SAMs of OPT n and OPD n on Ag, Au, and Pt. To our knowledge, there are few reports that correlate electronic spectroscopy of SAMs with molecular junction transport measurements,^{49–54} and so far none in which a principal property, namely ϵ_h , obtained from both transport and spectroscopy is compared for consistency. We find remarkably good agreement between transport- and UPS-derived ϵ_h for the cases of OPT n and OPD n , which is perhaps surprising in that clearly the transport measurement involves two contacts to each SAM, while the UPS analysis occurs on “half the junction”, namely just the SAM on the metal

substrate; there is no top contact. The close agreement of the two measurements of ϵ_h for 18 different types of junctions has a number of important consequences: it provides important insight into the band lineup problem for OPT n and OPD n with one contact vs two, it supports the physical picture of transport in these systems suggested by Figure 1A, and it confirms the SLM as a valuable theoretical tool for analysis of I – V characteristics of simple molecular junctions. We note for transparency that the I – V characteristics and SLM analysis of the OPD n system were reported in an earlier publication,⁴² and those results are reproduced here for the purpose of comparison to the OPT n system (i.e., for the comparison of the role of one chemical contact versus two). Importantly, UPS analysis and a comparison of $\epsilon_h^{\text{trans}}$ versus ϵ_h^{UPS} for OPD n were not reported previously and constitute a new and important aspect of the current study.

While the correspondence of ϵ_h derived from transport and spectroscopic measurements is our main result, we conclude this report with a discussion of the implications of the measured ϵ_h on the mechanisms of energy level lineup in molecular junctions, specifically the roles of image charge effects versus metal–molecule chemical bonding on the magnitude of ϵ_h .

EXPERIMENTAL METHODS

Materials. Gold nuggets (99.999% pure) were purchased from Mowrey, Inc. (St. Paul, MN). Silver pellets (99.99% pure) were purchased from Kurt J. Lesker Co.. Evaporation boats and chromium evaporation rods were purchased from R. D. Mathis (Long Beach,

CA). Platinum and titanium for e-beam evaporation were purchased from Kamis, Inc. (Mahopac Falls, NY). Silicon (100) wafers were obtained from WaferNet (San Jose, CA). Contact mode AFM tips (DNP silicon nitride probes) were purchased from Bruker AFM Probes. The benzene-1,4-dithiol (OPD1) 99%, *p*-terphenyl-4,4''-dithiol (OPD3) 96%, thiophenol (OPT1) 97%, biphenyl-4-thiol (OPT2) 97%, and 1,1',4',1''-terphenyl-4-thiol (OPT3) 97% used in this study were purchased from Sigma-Aldrich, and biphenyl-4,4'-dithiol (OPD2) 95% was purchased from TCI America.

Monolayer Growth and Characterization. Preparation of conducting tips and template-stripped flat Ag, Au, and Pt substrates are described in a previous publication.⁴² SAMs were formed by immersing clean template-stripped flat metal substrates into ethanol solutions of the molecules at a concentration of ~ 1 mM for 20 h. The chemical composition and thickness of the OPT and OPD SAMs were characterized by XPS (Figures S1 and S2 and Table S1 in the Supporting Information). Previously, we have characterized OPT and OPD SAMs by spectroscopic ellipsometry, Rutherford backscattering spectrometry, and nuclear reaction analysis.^{42,55,56} The HOMO–Fermi level offset of OPT and OPD SAMs on metals was measured by UPS (Figure S3 in the Supporting Information). During UPS acquisition, -5 V was applied to the sample to obtain the secondary electron cutoff to calculate the work function of the samples (cf. Figure S6 in the Supporting Information). Details of the XPS and UPS measurements are described in the Supporting Information. Scanning Kelvin probe microscopy (SKPM) measurements were used to determine the work function (Φ) with and without a SAM adsorbed on the metal surface ($\Phi_{\text{SAM}} = \Phi + \Delta\Phi$) (see Table 2). SKPM measurements were carried out using the same instrument that was employed for I – V characterization. The AFM instrument was housed in an Ar-filled glovebox (H_2O , $\text{O}_2 < 0.1$ ppm). The work functions of the samples were referenced to the UPS value of benzene-1,4-dithiol on an Au substrate.

Transport Measurements. Current–voltage measurements were completed by mounting the substrates in the AFM and bringing the metal-coated tip into contact with the SAM under ~ 1 nN of the applied compressive load (Figure 1B). Voltages were applied to the tip with a Keithley model 236 source-measure unit operated in “DC mode”. Voltage was swept at the tip, the sample was grounded, and current–voltage characteristics were recorded ($V > 0$ means positive voltage on the tip). All measured I – V curves crossed over from practically linear at low biases to gradually more nonlinear at higher biases. The inverse of the slope of the linear portion of the I – V characteristic was used to define a junction (low bias) resistance R . The tunneling attenuation parameter β and contact resistance R_c were extracted with high certainty from plots of the low bias resistance versus molecular length. Voltage sweeps to ± 1.2 – 1.5 V were applied to observe the pronounced nonlinear (I – V) behavior.

RESULTS AND DISCUSSION

At the outset, we reiterate the point made in the Introduction that the charge-transport properties of OPD n junctions with Ag, Au, and Pt contacts have been reported previously.⁴² The key extracted parameters ε_h and Γ are included here with the new monothiol OPT n data for the purpose of direct comparison. In addition, we present previously unreported UPS data for both OPT n and OPD n systems. A comparison of the transport and spectroscopy data sets for OPT n and OPD n allows us to make important conclusions about the role of chemical versus physical contacts on the energy level lineup problem for these π -conjugated systems.

Low Bias Resistance. In the case of off-resonant tunneling, it is known that low bias resistance scales exponentially with molecular length²

$$R_n = R_c \exp(\beta n L_0) \quad (1)$$

where R_c is the effective contact resistance, β is the tunneling decay parameter, L_0 is the molecular length in repeat units, and n is the number of repeat units. From the slope of a semilog plot of $R = R_n$ versus the number of units in the chain n , one can determine the tunneling attenuation factor β , and its intercept at $n = 0$ gives the effective contact resistance R_c . The low bias resistances of the junctions were calculated from the average of approximately 100–150 I – V traces within ± 0.1 V (Table 1). The linear relationships for OPT n and OPD n in

Table 1. Summary of the Main Results for OPT n CP-AFM Junctions: β Value in \AA^{-1} , Contact Resistance R_c , and Low Bias Resistance of the Junctions (Ω) and Transition Voltages $V_{t\pm}$ (V)^a

electrode	quantity	OPT1	OPT2	OPT3
Ag/Ag	R	4.22×10^6	4.12×10^7	5.27×10^8
$\beta = 0.58 \text{ \AA}^{-1}$	V_{t+}	1.18	0.96	0.79
$R_c = 3.55 \times 10^5$	$ V_{t-} $	1.31	1.1	0.94
Au/Au	R	5.28×10^4	3.78×10^5	1.93×10^6
$\beta = 0.51 \text{ \AA}^{-1}$	V_{t+}	0.94	0.81	0.67
$R_c = 5.79 \times 10^3$	$ V_{t-} $	1.08	0.98	0.87
Pt/Pt	R	1.18×10^4	1.14×10^5	1.17×10^6
$\beta = 0.55 \text{ \AA}^{-1}$	V_{t+}	0.83	0.72	0.6
$R_c = 1.18 \times 10^3$	$ V_{t-} $	0.97	0.84	0.69

^aThe corresponding data for OPD n are found in ref 42.

Figure 2 indicate that the data fit well within the off-resonance tunneling model described by eq 1. The β values of OPT n and OPD n found here are independent of metal work functions within the experimental uncertainty but strongly dependent on the number of the linkers, as reported previously for other SAM systems.^{42,51,57,58} The measured β -values are 2.3 and 1.5 per phenyl ring, or 0.54 and 0.37 \AA^{-1} , for the OPT n and OPD n wires, respectively. The contact resistances R_c , given by the intercepts of the Figure 2A plots, change markedly by altering the type of the metals, Figure 2B, as is now well-known.⁵⁷ For the electrodes studied (Ag, Au, and Pt), Φ increases by 1.4 eV and R_c decreases by a factor of 300 and 70 for OPT n and OPD n , respectively. The decreases in both R and R_c with Φ in Figure 2 indicate hole-type (HOMO-mediated tunneling), i.e., higher work function brings the metallic Fermi level closer to the HOMO.

Analysis of I – V Traces. For a more comprehensive examination of transport properties, we investigated the nonlinear (higher bias) regime of the I – V characteristics. Parts A and B of Figure 3 show the representative linear and semilog plots of the average I – V curves over ± 1.3 V for the Au–OPT n –Au junctions. Each average I – V trace is nearly, but not perfectly, symmetric with respect to zero bias; slightly higher current is observed for positive tip bias. For a given voltage, the current decreases exponentially with length. As shown in Figure 3C, we analyze the shape of these curves by recasting the plots on new axes, $|V^2/I|$ vs V .^{48,59} This type of plot gives a peak maximum, which corresponds to the point where the differential conductance is two times larger than the nominal pseudo-ohmic conductance.^{42,48} This approach is an alternative version of transition voltage spectroscopy (TVS), and the voltage at peak maximum and the transition voltage V_t (originally defined as the bias at the minimum of the Fowler–Nordheim plot⁶⁰) are mathematically identical.^{48,59}

Table 1 lists the V_t values at negative and positive bias for 9 OPT n junctions. In contrast to the independence of bias

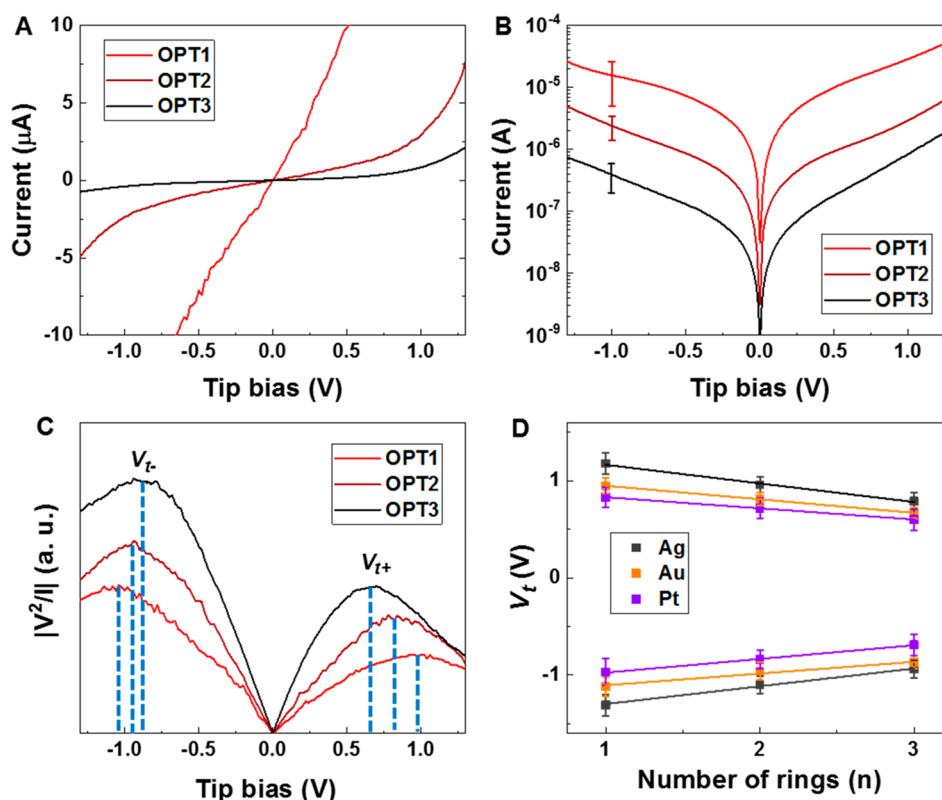


Figure 3. (A) Representative linear and (B) semilog plots of average I - V curves and (C) transition voltage spectra of Au- $\text{OPT}n$ -Au junctions. Transition voltages (V_t) are the voltages at the peak maxima, as shown. (D) Transition voltages of Ag- $\text{OPT}n$ -Ag, Au- $\text{OPT}n$ -Au, and Pt- $\text{OPT}n$ -Pt junctions.

Table 2. Key Electronic Structure Parameters Including the Energy offset $\epsilon_h^{\text{trans}}$, Conductance of Junctions G , Average Coupling Γ , and Orbital Voltage Shift Coefficient γ for $\text{OPT}n$ and $\text{OPD}n$ via the Single-Level Model (Transport)^a

metal	quantity	OPT1	OPT2	OPT3	OPD1	OPD2	OPD3
Ag	$\epsilon_h^{\text{trans}}$	1.08	0.89	0.74	1.00	0.87	0.73
	ϵ_h^{UPS}	1.12	0.99	0.92	0.83	0.80	0.79
	G	2.34×10^{-7}	2.43×10^{-8}	1.90×10^{-9}	1.20×10^{-5}	3.09×10^{-6}	5.34×10^{-7}
	Γ	7.14	1.88	0.44	43.94	19.45	6.82
	γ	0.023	0.029	0.038	0	0.004	-0.005
	$\Phi_{\text{SAM}}^{\text{UPS}}$	3.84	3.96	4.03	4.84	4.93	4.89
	$\Phi_{\text{SAM}}^{\text{SKPM}}$	4	4.14	4.12	4.61	4.55	4.55
Au	$\epsilon_h^{\text{trans}}$	0.87	0.76	0.66	0.87	0.73	0.56
	ϵ_h^{UPS}	0.77	0.72	0.68	0.82	0.74	0.68
	G	1.89×10^{-5}	2.65×10^{-6}	5.18×10^{-7}	1.65×10^{-4}	3.73×10^{-5}	6.65×10^{-6}
	Γ	52.65	16.82	4.52	141.65	56.57	18.34
	γ	0.036	0.037	0.055	0.004	-0.005	-0.003
	$\Phi_{\text{SAM}}^{\text{UPS}}$	4.72	4.24	4.11	4.72	4.72	4.8
	$\Phi_{\text{SAM}}^{\text{SKPM}}$	4.78	4.36	4.27	4.72	4.77	4.72
Pt	$\epsilon_h^{\text{trans}}$	0.77	0.67	0.56	0.75	0.63	0.49
	ϵ_h^{UPS}	0.78	0.69	0.62	0.81	0.72	0.60
	G	8.47×10^{-5}	8.77×10^{-6}	8.55×10^{-7}	1.11×10^{-3}	1.88×10^{-4}	4.17×10^{-5}
	Γ	96.30	27.00	6.98	317.63	109.79	40.14
	γ	0.034	0.033	0.030	-0.005	0	-0.012
	$\Phi_{\text{SAM}}^{\text{UPS}}$	4.52	4.48	4.37	4.81	4.84	4.77
	$\Phi_{\text{SAM}}^{\text{SKPM}}$	4.24	4.27	4.27	4.45	4.59	4.66

^aAlso included are ϵ_h^{UPS} and work function for $\text{OPT}n$ and $\text{OPD}n$ by UPS ($\Phi_{\text{SAM}}^{\text{UPS}}$) and by SKPM ($\Phi_{\text{SAM}}^{\text{SKPM}}$). Units: ϵ_h in eV, G in S, Γ in meV obtained from eq 6 by assuming $N = 70$ molecules for $\text{OPT}n$ and $N = 80$ molecules for $\text{OPD}n$ according to the Maugis–Dugdale (MD) model of contact mechanics, Φ in eV.^{46,55} Details of the work function determination are described in the Supporting Information (cf. Figure S6). The UPS data have an error of ± 0.1 eV.

polarity for V_t in $\text{OPD}n$ symmetric junctions ($|V_{t-}| = V_{t+}$),⁴² the V_t of $\text{OPT}n$ junctions show bias polarity dependence $|V_{t-}|$

$> V_{t+}$. Also, V_t decreases with increasing length of $\text{OPT}n$, and it also decreases with increasing work function of the contact

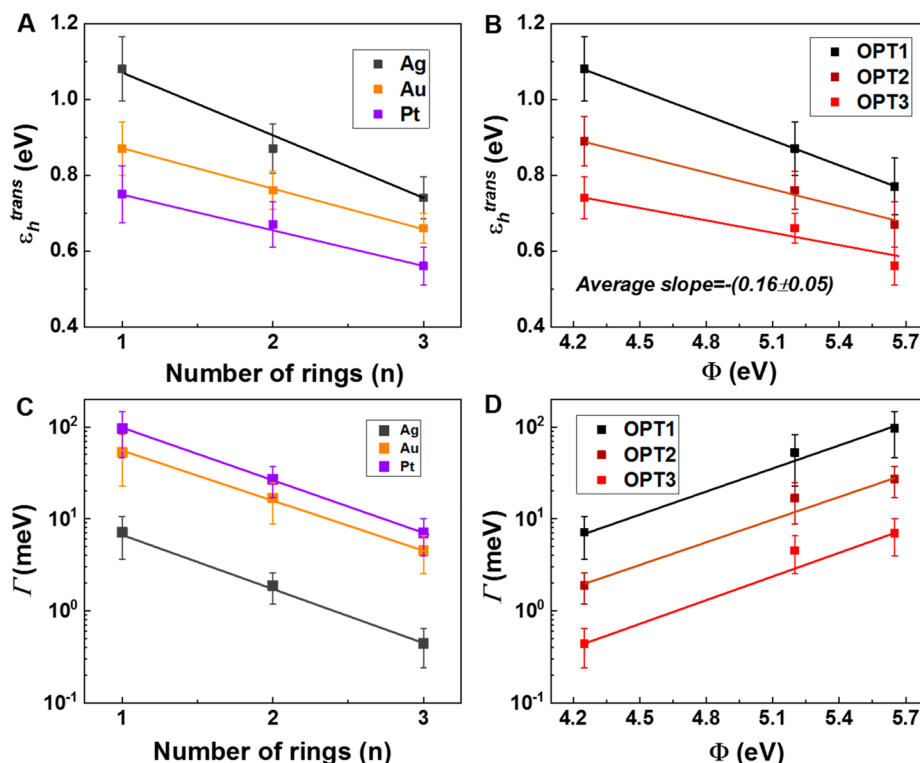


Figure 4. HOMO offset (or effective tunneling barrier) $\epsilon_h^{\text{trans}}$ for metal–OPT n –metal junctions as a function of (A) molecular length n and (B) bare electrode work function Φ . The average molecule–electrode coupling (or average level width) Γ of metal–OPT n –metal junctions as a function of (C) molecular length n and (D) bare electrode work function Φ (metal = Ag, Au, Pt; $n = 1, 2, 3$).

metals, as shown in Figure 3D. Importantly, V_t can be employed to calculate the effective energy offset ϵ_h of the junctions by using the SLM.^{41,42} In the case of molecular junctions with asymmetric I – V characteristics ($|V_{t-}| \neq V_{t+}$, e.g., OPT n), the magnitude of the energy offset of the occupied level ($\epsilon_h = E_F - E_{\text{HOMO}} > 0$) that dominates the charge transport is expressed as follows:⁴¹

$$\epsilon_h = 2 \frac{e|V_{t+}V_{t-}|}{\sqrt{V_{t+}^2 + 10|V_{t+}V_{t-}|/3 + V_{t-}^2}} \quad (2)$$

For *symmetric* junctions ($V_{t-} \approx V_{t+}$), the correlation between transition voltage V_t and the effective tunneling barrier ϵ_h is $\epsilon_h = \sqrt{3} V_t/2e$.^{41,42} For *asymmetric* junctions, the molecular orbital (HOMO in this case) energy $E_{\text{HOMO}}(V)$ in a biased junction ($V \neq 0$) is shifted with respect to its position in the absence of bias $E_{\text{HOMO}} \equiv E_{\text{HOMO}}(V = 0)$ by a quantity proportional to V .^{41,61}

$$\begin{aligned} E_{\text{HOMO}}(V) &= E_{\text{HOMO}} + \gamma eV, \\ \epsilon_h(V) &= E_F - E_{\text{HOMO}}(V) = \epsilon_h - \gamma eV \end{aligned} \quad (3)$$

where the orbital shift coefficient γ is given by

$$\gamma = -\frac{1}{2} \frac{V_{t+} + V_{t-}}{\sqrt{V_{t+}^2 + 10|V_{t+}V_{t-}|/3 + V_{t-}^2}} \quad (4)$$

The I – V characteristics are then given as^{41,42}

$$I = GV \frac{\epsilon_h^2}{[\epsilon_h(V)]^2 - (eV/2)^2} = GV \frac{\epsilon_h^2}{(\epsilon_h + \gamma eV)^2 - (eV/2)^2} \quad (5)$$

The zero-bias conductance $G = 1/R$ of the CP-AFM junction can be expressed as follows

$$G = N G_0 \frac{\Gamma^2}{\epsilon_h^2} \quad (6)$$

where $\Gamma = \sqrt{\Gamma_s \Gamma_t} = \epsilon_h \sqrt{G/(N G_0)}$ is the average molecule–electrode coupling, Γ_s and Γ_t are determined by the molecular coupling to the substrate (s) and tip (t), respectively ($\Gamma_s \approx \Gamma_t$ in symmetric junctions), $G_0 = 2e^2/h$ is the quantum conductance, and N is the number of molecules participating in the transport.

The effective energy offsets $\epsilon_h^{\text{trans}}$ for OPT n molecular junctions determined via eq 2 are listed in Table 2 and are plotted in Figure 4. The trend in $\epsilon_h^{\text{trans}}$ with molecular length for Ag, Au, and Pt contacts is shown in Figure 4A, where it is clear that $\epsilon_h^{\text{trans}}$ decreases systematically with n , similar to our previous report for OPD n .⁴² The dependence of $\epsilon_h^{\text{trans}}$ on the bare electrode work function Φ is evident in Figure 4B. The fact that the slopes are significantly less than one is an indication of Fermi level pinning,^{42–44,51} i.e., large changes in contact work function (~ 1.4 eV) produce only relatively modest changes (~ 0.2 eV) in $\epsilon_h^{\text{trans}}$, as has also been reported before for several different molecular junctions.^{42–44,51} Notably, the relatively weak dependence of the effective tunneling barrier $\epsilon_h^{\text{trans}}$ on molecular length n and metal work function Φ evident in Figure 4A,B cannot be responsible for the much larger (orders of magnitude) differences in resistance with n and Φ shown in Figure 2. It is the molecule–electrode couplings Γ , calculated by eq 6, that drastically change with n and Φ , Table 2 and Figure 4C,D. The strength of the molecule–electrode couplings of OPT junctions decreases

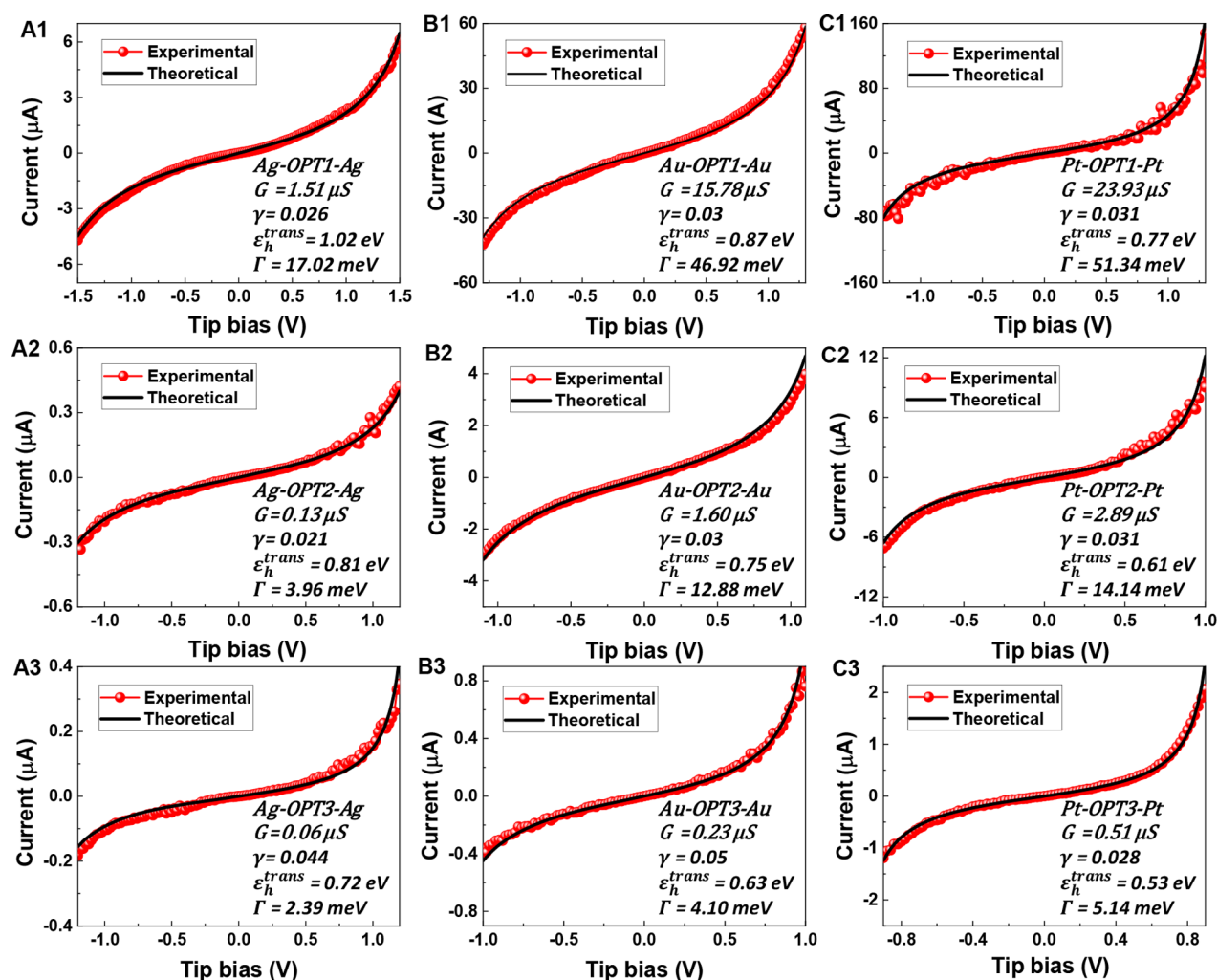


Figure 5. Experimental I - V curves (red) and single-level model simulations via eq 5 (black) for (A1–3) Ag–OPT n –Ag, (B1–3) Au–OPT n –Au, and (C1–3) Pt–OPT n –Pt junctions. The three extracted parameters for each junction, low bias conductance G ($1/R$), the energy offset ϵ_h^{trans} and orbital shift factor γ are listed in each panel. The calculated coupling strengths Γ (calculated from G via eq 6) are also provided. Note that G is determined by the (ohmic) low bias conductance and ϵ_h^{trans} and γ are determined from transition voltage plots (Figure 3C) and eqs 2 and 4. Thus, none of the parameters shown are freely adjusted.

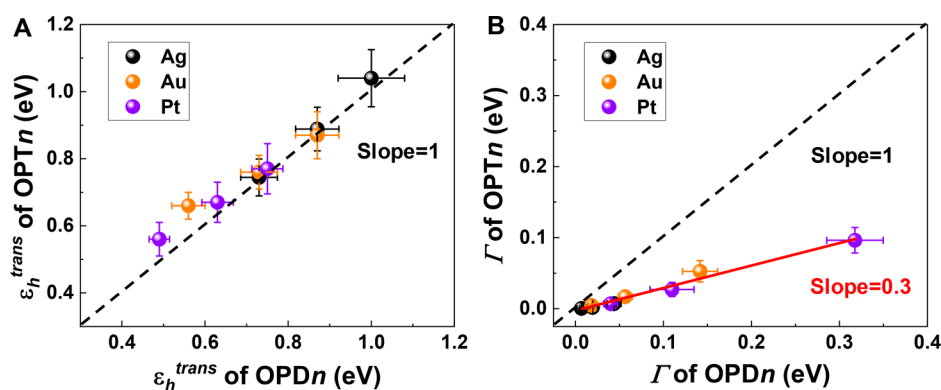


Figure 6. HOMO energy offset ϵ_h^{trans} (A) and coupling Γ (B) for OPT n vs OPD n with Ag, Au, and Pt contacts. ϵ_h^{trans} and Γ were extracted from I - V characteristics using the single-level model. The dashed lines show the trends for perfect correspondence. The red line in panel B represents the linear fit.

systematically, $\Gamma_{Ag} < \Gamma_{Au} < \Gamma_{Pt}$, with an exponential falloff with increasing length n in each molecular set as well. Thus, we ascribe the strong change in junction resistance R (Figure 2) to be primarily related to the changes in Γ^2 .

Simulation of I - V Curves Using the Single-Level Model. An important verification of the SLM is whether it accurately predicts the measured I - V behavior. Using the extracted values of ϵ_h^{trans} , γ , and low bias G (from which we

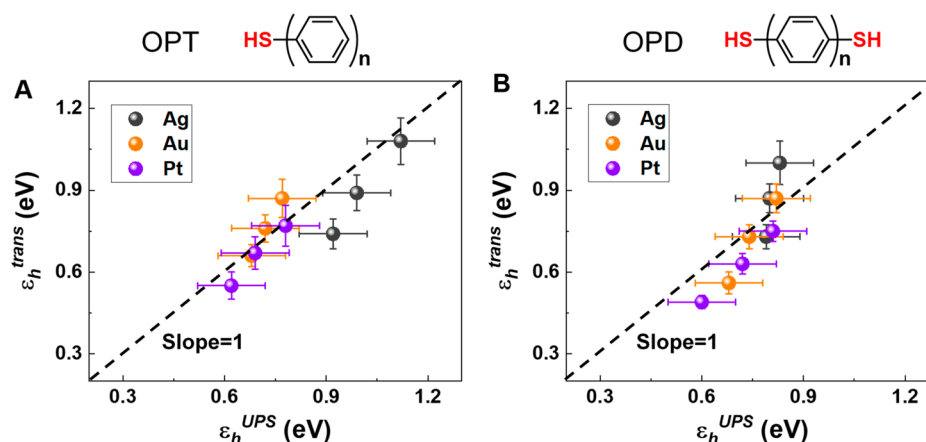


Figure 7. Correlation of $\epsilon_h^{\text{trans}}$ from transport measurements (and the single-level model) with ϵ_h^{UPS} from UPS measurements for (A) OPT n and (B) OPD n molecular junctions with Ag, Au, and Pt contacts. The dashed lines show the trends for perfect correspondence.

calculate Γ directly by eq 6), the I – V data for all junctions were simulated with eq 5. Indeed, eq 5 reproduces the individual I – V curves measured for our CP-AFM junctions extremely well, as shown in Figure 5 for individual I – V traces collected from nine Ag–OPT n –Ag, Au–OPT n –Au, and Pt–OPT n –Pt junctions. The fitting of symmetric OPD n junctions has been reported previously.⁴² Importantly, G , $\epsilon_h^{\text{trans}}$, and γ in eq 5 were not taken as adjustable parameters to achieve these fits. Rather, G is obtained directly from the measured low bias resistance, and ϵ_h and γ are calculated via eqs 2 and 4 from the measured transition voltage V_t (see Figures 3 and 4). These values were inserted into eq 5 to compute the I – V traces directly, which indeed matched the data. Of course, this is really a self-consistency check as eqs 2 and 4 derive from the SLM described by eq 5. We believe the high quality of the simulations justifies the use of the single-level model for analysis of the OPT n and OPD n molecular junctions; we provide further support for the SLM below.

Comparison of OPT n and OPD n Transport. For a given type of electrode and the same number of phenylene repeat units (n), the resistance of a dithiol junction (OPD n) is always smaller than its monothiol (OPT n) counterpart by 1–2 orders of magnitude (Figure 2),⁴² although the OPD n length is larger than the OPT n length by the extra S-metal bond. The higher resistance of OPT n versus OPD n junctions is ascribed to the different nature of the top contact (physisorbed versus chemisorbed).^{51,62–67} Figure 6A and Table 2 show that, interestingly, there is no obvious difference in the energy offset $\epsilon_h^{\text{trans}}$ (or tunneling barrier) induced by the different nature of the contacts; the $\epsilon_h^{\text{trans}}$ values of OPT n are remarkably close to that of OPD n , Table 2. Thus, differences in ϵ_h cannot explain the large conductance difference between OPT n and OPD n junctions. The conductance difference between dithiols and monothiols is due to Γ . As shown in Figure 6B (and listed in Table 2), the average Γ of OPD n are higher than OPT n by factors of 3–15 depending on length and metal type, which results in 1–2 orders of magnitude difference in junction resistance (eq 6, $R \propto 1/\Gamma^2$). Γ is proportional to the square root of Γ_t (cf. eq 6), and Γ_t for the phenyl/tip contact is correspondingly smaller than for the thiol/tip contact. The findings here for OPT n versus OPD n are consistent with numerous examples in the literature for two-terminal tunnel junctions in that two chemical contacts lead to higher junction

conductances than one chemical and one physical contact.^{51,64–70}

UPS Measurements of ϵ_h and Implications. To obtain independent verification of the energy level alignment $\epsilon_h^{\text{trans}}$ determined by transport, we undertook analysis of OPT n and OPD n SAMs by UPS, which is the standard experimental method to sample occupied electronic states.^{71–73} The spectra for OPT1–3 and OPD1–3 on Ag, Au, and Pt substrates, respectively are shown in Figures S4 and S5 in the Supporting Information. In these binding energy spectra, the Fermi edge is clearly evident and the HOMO onsets were determined using standard extrapolation protocols as indicated.^{53,54} The resulting 18 ϵ_h^{UPS} values obtained by UPS for OPT1–3 and OPD1–3 are compared to the corresponding 18 $\epsilon_h^{\text{trans}}$ values obtained by transport (Table 2 and Figure 7). For OPT n , agreement between ϵ_h^{UPS} and $\epsilon_h^{\text{trans}}$ is excellent; most of the data points in Figure 7A lie, within error, on the slope = 1 trendline, i.e., ϵ_h^{UPS} and $\epsilon_h^{\text{trans}}$ are essentially the same, within error. For OPD n , Figure 7B, the correspondence is also reasonable, but not as good as for OPT n . However, we might anticipate greater deviation between ϵ_h^{UPS} and $\epsilon_h^{\text{trans}}$ for OPD n because the additional –SH functional group of the OPD molecules provides a terminal dipole that can affect ionization potentials in UPS. In light of the potential complexity that the terminal –SH introduces for UPS measurements on OPD n compared to OPT n , the good correlation evident in Figure 7B is gratifying.

Two important points follow here. First, the general agreement between ϵ_h^{UPS} and $\epsilon_h^{\text{trans}}$ is an important validation of the SLM for OPT n and OPD n junctions, as SLM was central to determining $\epsilon_h^{\text{trans}}$. The applicability of SLM to molecular junctions has been emphasized by us many times,^{42–45,47} and indeed, we have noted that for the experimentalist the ability to rapidly extract important electronic structure parameters from I – V characteristics with a simple analytical model is invaluable. Until now, however, we have not presented clear evidence that the energies obtained from the model have direct correspondence with the independently measured electronic structure of the junction. The agreement in Figure 7 is thus a critical demonstration.

Second, we note that ϵ_h^{UPS} and $\epsilon_h^{\text{trans}}$ agree in spite of the fact that the UPS measurement probes only “half the junction” (i.e., there is no second contact), and this has important implications for the mechanism of energy level alignment.

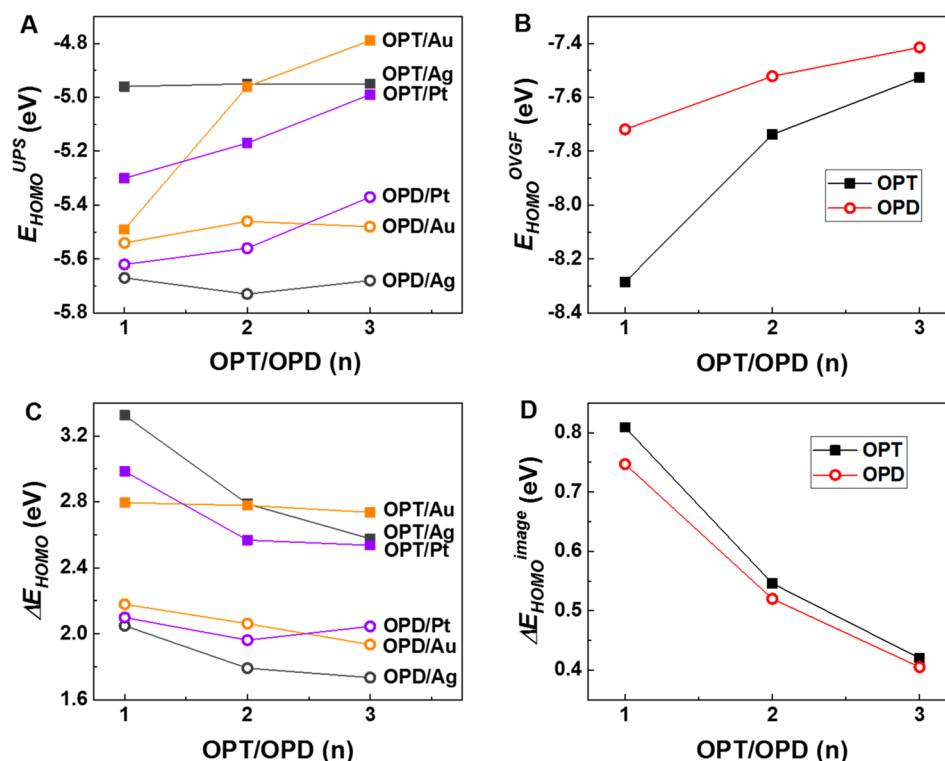


Figure 8. (A) HOMO energies relative to the vacuum level, $E_{\text{HOMO}}^{\text{UPS}} = -(\Phi_{\text{SAM}} + \epsilon_{\text{h}}^{\text{UPS}})$, of OPT_n and OPD_n SAMs adsorbed on Ag, Au, Pt substrates obtained via UPS measurements (see also Table 2). (B) HOMO energies $E_{\text{HOMO}}^{\text{OVGF}}$ for the isolated OPT_n and OPD_n molecules obtained via OVGF calculations. (C) Shift in HOMO energies $\Delta E_{\text{HOMO}} = E_{\text{HOMO}}^{\text{UPS}} - E_{\text{HOMO}}^{\text{OVGF}}$ for OPT_n and OPD_n SAMs relative to the isolated molecules. (D) Shift in HOMO energies expected in the case of image charge effects. For this calculation, a typical value $\epsilon_r = 2.3$ was used for the dielectric constant of the SAMs.

Evidently, binding of an OPT or OPD molecule to a metal via a single thiol group essentially fixes ϵ_{h} ; introducing a second, chemically or physically bonded metal contact has a minimal impact on ϵ_{h} . This finding implies that image charge effects, commonly invoked in discussions of energy level alignment in molecular junctions, must be reasonably small, as the effects of a second contact would be expected to be roughly additive. By “energy level alignment” we mean the upward or downward shifts of occupied or unoccupied MOs, respectively, relative to the same MOs in the isolated, gas-phase state. To emphasize our point regarding the role of image charges, we make a quantitative comparison below of the total HOMO shift measured for OPT_n and OPD_n on binding to a metal substrate and the predicted image charge shift due to proximity of the metal substrate.

The upward shifts of the HOMOs for OPT_n and OPD_n SAMs can be estimated by taking the difference between the HOMO ionization potential (IP) measured here by UPS ($E_{\text{HOMO}}^{\text{UPS}}$) and the gas phase IP of the isolated molecules. The experimental values of $E_{\text{HOMO}}^{\text{UPS}}$ for OPT_n and OPD_n SAMs are shown in Figure 8A. Unfortunately, IPs of the isolated OPT_n and OPD_n molecules are not generally known and so must be calculated. Only data for benzenethiol (OPT1) in the gas phase exist. The experimental value IP ≈ 8.3 eV of the lowest ionization energy can be trusted, as it was measured by means of a variety of methods (photoelectron spectroscopy, time-resolved dissociation, charge transfer spectroscopy, photo-ionization mass spectroscopy).^{74–77} For the isolated OPT1, the outer valence Green’s function (OVGF) approach using 6-311++g(d, p) basis sets as implemented in the GAUSSIAN 09 package⁷⁸ yields the value $-E_{\text{HOMO}}^{0,\text{OVGF}} = \text{IE} = 8.285$ eV, which

excellently agrees with the experimental value. In view of this agreement, we are confident that using the theoretical OVGF/6-311++g(d, p) estimates of $E_{\text{HOMO}}^{0,\text{OVGF}}$ for all of the isolated molecular species OPT_n and OPD_n is justified.

We note parenthetically that with the 6-311++g(d,p) basis sets the DFT approaches based on the LDA and GGA-PBE exchange correlation functionals—which belong to the class of nonhybrid exchange-correlation functionals (the only ones implemented in available packages for molecular transport (like SIESTA and ATK))—predict for the isolated OPT1 molecule values of the Kohn–Sham HOMO energy $E_{\text{HOMO}}^{0,\text{KS}}$ amounting to -6.021 and -5.416 eV, respectively. Because, in principle, DFT approaches based on hybrid exchange-correlation functionals might perform better, we computed the Kohn–Sham HOMO energy values of -6.404 eV and -6.208 eV by employing PBE0 and B3LYP, respectively, that is, two of the most recommended hybrid exchange-correlation functionals. It should be clear from above that a quantitative analysis of image charge effects based on DFT estimates of the HOMO energies cannot be trusted.

The OVGF results for E_{HOMO}^0 of the isolated OPT_n and OPD_n are depicted in Figure 8B. By subtracting the complete HOMO energies of the isolated molecules (Table S2 and Figure 8B) from the HOMO energies of the molecules coupled to substrates obtained via UPS (Table 2 and Figure 8A) we estimate the shifts $\Delta E_{\text{HOMO}}^0 = E_{\text{HOMO}}^{\text{UPS}} - E_{\text{HOMO}}^0$ in the HOMO energies due to the substrate, which are shown in Figure 8C. The shifts are on the order of 2–3 eV. The question is its origin: is it due predominantly to metal–molecule bonding or to image charge effects?

Upward (downward) energy shifts of occupied (unoccupied) molecular orbitals of molecules adsorbed on electrodes with respect to their positions in isolated molecules are often assigned as image charge effects in literature,^{34,79} i.e., the decreases in ionization potentials (electron affinities) for orbitals in the vicinity of a metal.⁸⁰ Given the delocalized nature of the HOMOs in both OPT n and OPD n (cf. Figure S7), the popular description assuming a pointlike MO is not adequate.^{79,81} For delocalized orbitals, integration over the spatial MO distribution is needed to estimate the image-driven MO shift.⁸² The HOMO energy shifts obtained for OPT n and OPD n by applying this procedure explained in detail in ref 82 are presented in Figure 8D. As the image-driven shifts in Figure 8D are 15–35% of the estimated HOMO shifts in Figure 8C, the cause of the HOMO energy shifts for OPT n and OPD n SAMs on Ag, Au, and Pt can be safely said to be largely due to S–metal covalent bonding, not image charge effects. Although this conclusion may be surprising in view of the increasing popularity of assigning MO shifts in molecular electronic devices to image charges, it is fully in line with well-established wisdom.⁷² Shifts due to electrostatic interactions with image charges are expected to be important for electronic states of the adsorbed molecule that are localized on the adsorbate rather than shared in covalent bonds with the electrodes.⁷² Clearly, the latter situation is the case for OPT n and OPD n systems anchored via thiol groups forming strong covalent S–M (M = Ag, Au, Pt) bonds.

CONCLUSION

Our combined experimental and single-level model analysis of transport for OPT n monothiols with Ag, Au, and Pt contacts reveals both notable similarities and differences with the previously reported results for OPD n dithiols.⁴² Specifically, the effective tunnel barrier ϵ_h is the same within error for the two systems and is only weakly dependent on molecular length n and metal work function Φ , whereas in stark contrast, the molecule–electrode electronic coupling Γ is significantly higher for OPD n than for OPT n and is strongly dependent on n and Φ . Several conclusions follow from these results, namely that (1) chemically bonded (i.e., metal–S) contacts produce larger electronic couplings Γ , as has been shown in the literature,^{70,83} and thus, the second (tip–SAM) contact has a large effect on Γ ; (2) the second (tip–SAM) contact has only a weak effect on ϵ_h , meaning that ϵ_h is effectively set for OPT n and OPD n by the first metal–S bond; (3) the length dependence of transport characterized by the empirical attenuation factor β is largely determined by Γ , not ϵ_h , for both OPT n and OPD n with all three metal contacts; (4) Fermi level pinning, i.e., a weak dependence of ϵ_h on Φ , is germane to both OPT n and OPD n , which corresponds well with prior reports on other SAMs systems; (5) correspondingly, the Φ dependence of transport, which can be empirically characterized by the contact resistance R_c , is largely dependent on Γ , not ϵ_h .

Most significantly, our independent measurements of the occupied electronic states of OPT n and OPD n SAMs by UPS provide values of ϵ_h^{UPS} that agree remarkably well with the transport estimates $\epsilon_h^{\text{trans}}$ for both systems. This provides compelling support for the application of the single-level model to the analysis of OPT n and OPD n molecular junctions. The relevance of the SLM for molecular junctions has so far been based on the outstanding fits of the SLM to the I – V characteristics of junctions composed of a wide range of

molecules. The comparison with UPS results reported here is the first time that the extracted values of $\epsilon_h^{\text{trans}}$ have been shown to be in excellent agreement with electronic spectroscopy, and thus provides an important demonstration of the value of the SLM for the case of these simple molecular junctions. Our corroborating OVGF calculations have further shown that ϵ_h is largely set by the metal–S bonding (i.e., quantum mechanical effects) and not by classical image charge stabilization. Overall, our results provide a more complete physical picture for the electronic factors impacting tunneling in SAM-based molecular junctions and demonstrate the utility of the compact single-level model for aiding the analysis of structure–transport relationships.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/jacs.8b13370.

Experimental and theoretical details, supplementary tables and figures (PDF)

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Notes

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